

ISSUE CLASSIFICATION	
Class	Subclass
854	452

PATENT NUMBER

N.

U.S. UTILITY Patent Application

O.I.P.E.		PATENT DATE
SCANNER <u>SP3</u>	O.A. <u>VR</u>	

APPLICATION NO. 09/998993	CONT/PRIOR	CLASS 438	SUBCLASS	ART UNIT 2812	EXAMINER
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APPLICANTS

Michael Turner
Waikit Fong
Oliver Graudejus
Doug Winandy

TITLE

Phosphorous-doped silicon dioxide process to customize contact etch profiles

PTO-2040
12/99

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ISSUING CLASSIFICATION									
ORIGINAL			CROSS REFERENCE(S)						
CLASS	SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)					
438	784		438	763	783	789	790		
INTERNATIONAL CLASSIFICATION									
A	O	I.L.	21/31						

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<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg. 5	Figs. Drwg. 8	Print Fig. Fig 5	Total Claims 25
The term of this patent subsequent to _____ (date) has been disclaimed.	<i>Julio D. Maldonado</i> (Assistant Examiner)		NOTICE OF ALLOWANCE MAILED _____ (Date)	
The term of this patent shall not extend beyond the expiration date of U.S. Patent. No. _____ _____ _____	_____ (Primary Examiner) _____ (Date)		ISSUE FEE Amount Due _____ Date Paid _____	
The terminal _____ months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) _____ (Date)		ISSUE BATCH NUMBER _____	
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